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### High temperature SU-8 pyrolysis for fabrication of carbon electrodes

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### Abstract

In this work, we present the investigation of the pyrolysis parameters at high temperature (1100°C) for the fabrication of two-dimensional pyrolytic carbon electrodes. The electrodes were fabricated by pyrolysis of lithographically patterned negative epoxy based photoresist SU-8. A central composite experimental design was used to identify the influence of dwell time at the highest pyrolysis temperature and heating rate on electrical, electrochemical and structural properties of the pyrolytic carbon: Van der Pauw sheet resistance measurements, cyclic voltammetry, electrochemical impedance spectroscopy and Raman spectroscopy were used to characterize the pyrolytic carbon.

The results show that the temperature increase from 900°C to 1100°C improves the electrical and electrochemical properties. At 1100°C, longer dwell time leads to lower resistivity, while the variation of the pyrolysis parameters has small influence on electrochemical performance.

### Keywords

Pyrolytic carbon, photoresist, pyrolysis, resistivity, electrochemistry

### 1. Introduction

Carbon electrodes have been widely studied due to their favorable properties including wide electrochemical potential window, chemical inertness, low fabrication costs and electrocatalytic activity for many redox reactions [1]. For this reason, various carbon allotropes such as highly oriented pyrolytic graphite, graphene, carbon nanotubes and carbon films have been investigated for numerous electrochemical applications including electroanalysis [2], electrocatalysis [3,4] or energy conversion and storage [5,6]. In particular, thin conductive carbon films with thickenss below hundreds of micron can be obtained using a pyrolysis process. Based on the precursor material used, different fabrication methods are available such as the pyrolysis of gases [7], graphite oxides [8] or electro-grafted layers derived from diazonium [9]. A promising approach to obtain thin carbon films with well-defined geometries is based on the pyrolysis of lithographically patterned photoresists [10–13]. The advantage of this process is that it is simple, highly reproducible and offers the possibility to customize the final electrode design. The resulting carbon is structurally and electrochemically similar to glassy carbon, with a microstructure composed of both graphitic (sp<sup>2</sup> hybridization of C bonds) and amorphous (sp<sup>3</sup> hybridization of C bonds) zones [10,11,14,15].

Pyrolytic carbon obtained from photoresists has been used for example for the fabrication of microbatteries [16,17], and due to its biocompatibility [18] also for biosensors [19–21], cell culturing and differentiation [22] and bioparticle sorting and manipulation using dielectrophoresis [23].

Previous studies showed that depending on the pyrolysis conditions, the graphitic content is modified and that consequently the electrical and electrochemical properties of the carbon can be changed [14,24,25]. The parameters to be varied include maximum pyrolysis temperature, heating rate, number of temperature steps, dwell time at the maximum temperature and gas composition inside the furnace. In general, it has been shown that processes with higher temperatures lead to pyrolytic carbon with lower resistivity and better electrochemical performance [10,14,25].

The typical process used to pyrolyze photoresists consists of a treatment at 900°C in nitrogen or forming gas, with a heating rate of 10 °C/min. It has been reported that under these conditions parameters such as dwell time or heating rate have an effect on the porosity of the pyrolytic carbon [25,26]. Only a few authors have shown experiments performed at 1100°C, which represents the highest temperature achievable in quartz based furnaces [14,25]. The results indicate that higher temperatures are beneficial for electrode properties. However, to date no detailed experimental study of electrode fabrication with photoresists precursors pyrolyzed at elevated temperature has been reported. Here, we systematically investigate the influence of the pyrolysis conditions at 1100°C. The aim of the study was to achieve low resistivity and improved electrochemical performance of pyrolytic carbon electrodes.

The pyrolysis temperature (1100°C), the gas environment ( $N_2$ ) and number of temperature steps (onestep) were defined as fixed parameters in our study. The effects of different heating rates and dwell times at the maximum temperature were investigated. These two parameters were chosen to perform a central composite experimental design to investigate their influence on the electrical and electrochemical properties of the carbon electrodes.

Resistivity of the pyrolytic carbon was measured with a custom-made four terminal setup using the Van der Pauw (VdP) method [27,28]. The electrochemical behavior was evaluated with cyclic voltammetry (CV) and electrochemical impedance spectroscopy (EIS) using the redox couple ferriferrocyanide  $[Fe(CN)_6]^{4-}$  /  $[Fe(CN)_6]^{3-}$ , a commonly used probe to investigate the electrochemical properties of material surfaces.

# 2. Material and methods

# 2.1. Fabrication of pyrolytic carbon electrodes

Two different devices were designed and fabricated to characterize the pyrolytic carbon properties. 2D electrode chips were used to investigate the electrochemical properties. Custom-made square devices were used to perform Van der Pauw measurements and determine the electrical resistivity of the pyrolytic carbon films. The 2D electrode chips ( $10mm \times 30mm$ ) consist of a three-electrode system where a circular carbon working electrode (WE) has an area of 12.5 mm<sup>2</sup> (figure 1A). The counter electrode has an area of 25.2 mm<sup>2</sup>. The contact leads are made of a carbon layer (length 10 mm, width 700µm) covered by Au with an adhesion layer of Ti or Cr (length 18 mm, width 1 mm) as shown in figure 1B. The Au pseudo-reference electrode (RE) has an area of 0.8 mm<sup>2</sup>. Finally, the chip is covered by an insulating SU-8 passivation layer, except for the sensing area and the contact pads (figure 1C).The VdP devices have a 25 mm<sup>2</sup> area of pyrolytic carbon, surrounded by Au contacts as reported in figure 1D [28].

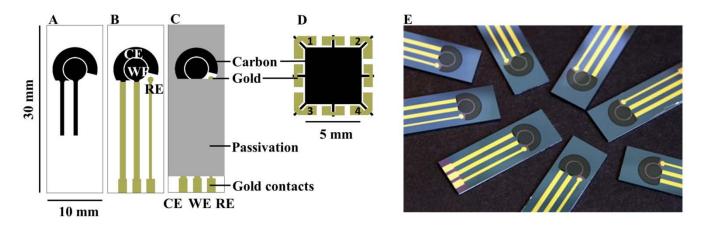


Figure 1. Overview of 2D carbon electrodes: carbon layer (A), gold contact leads and pads (B), SU-8 passivation layer (C), Van der Pauw device for 4-point probe measurements (D), electrochemical electrodes (E).

The fabrication process is illustrated in figure 2. 4-inch silicon wafers with 600 nm Si oxide grown by wet oxidation were used as substrates. First, the negative photoresist SU-8 2035 (Microresist GmbH) was dispensed manually and spin coated using a RCD8 spin coater (Süss MicroTec) (figure 2A and 2B). A two-step process was used to obtain a thickness of 17  $\mu$ m: 1000 rpm for 10 seconds with an acceleration of 200 rpm/s followed by 5000 rpm for 120 seconds with an acceleration of 1000 rpm/s (figure 2B). Subsequently, the wafers were placed on a programmable hot plate (Harry Gerstigkeit GmbH) for soft bake (50 °C for 15 minutes) and then exposed using a chromium mask and a MA6/BA6 mask aligner with 365nm wavelength (Süss MicroTec) in soft contact mode. The exposure dose used was 2x250 mJ/cm<sup>2</sup> with 30 seconds of waiting time between the two exposures (figure 2D). The development was performed in propylene glycol methyl ether acetate (PGMEA) using two subsequent immersions of 5 minutes each. The wafers were then rinsed with isopropanol and dried in air. An additional flood exposure step was performed to complete the crosslinking of the structures (2x250 mJ/cm<sup>2</sup> and 30 seconds of waiting time). Finally, the wafers were hard-baked for 15 hours at 90°C (figure 2E).

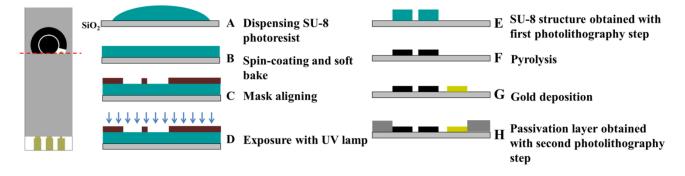


Figure 2. Electrode fabrication process flow.

The pyrolysis of the SU-8 structures was performed in a PEO-604 furnace (ATV Technologie GmbH). Once the samples were pyrolyzed (figure 2F), 20 nm of titanium or chromium adhesion layer and 200 nm of gold were deposited by e-beam evaporation (Alcatel SCM 600) through a shadow mask to define the contact leads and pads (figure 2G).

Finally, to obtain 5  $\mu$ m of passivation layer another lithography step was used. SU-2005 was spin coated at 2000 rpm for 30 seconds with an acceleration of 500 rpm/s. After solvent evaporation of 2 hours at room temperature, the substrate was exposed using a chromium mask and a dose of 2x250 mJ/cm<sup>2</sup> with 30 seconds of waiting time. This was followed by a 1 hour bake at 50°C, rinse in PGMEA, flood exposure with the same parameters as the previous exposure and final hard bake of 15 hours at 90°C (figure 2H). The wafers were then cut using a dicing saw (Automatic Dicing Saw, DAD321, DISCO) to obtain single chips.

### 2.2. Design of experiment for investigation of pyrolysis conditions

The chosen parameters for the experimental design were the dwell time at the maximum temperature (t: 1 hour, 3 hours, and 5 hours) and the heating rate (h: 10°C/min, 30°C/min, 50°C/min). The experiment was carried out using a face centered central composite design [29] with full randomization and 2 center points resulting in 10 experimental runs in total. SAS JMP software package was used to analyze the results and identify the influence of the chosen parameters. The measured responses were resistivity, anodic peak current, peak potential separation  $\Delta E_p$  and thickness after pyrolysis. Formally, the regression model used in the analysis was:

$$Y = \beta + a_1 t + a_2 h + a_3 t h + a_4 t^2 + a_5 h^2 \quad (eq. 1)$$

where Y is either the resistivity, the anodic peak current,  $\Delta E_p$  or thickness after pyrolysis, t is the dwell time and h is the heating rate. Hence four distinct models are fitted each with different intercept  $\beta$  and regression coefficients  $a_i$ . A factor is then defined significant if the corresponding regression coefficient is different from zero under the null hypothesis  $H_0$ :  $a_i = 0$  where the testing is carried out using the t test.

The standard least squares approach was used to fit the data to the model. This method finds the response surface that minimizes the sum of the squares of the residuals of the points from the response surface.

For comparison with the state-of-the art process, the results of the characterization of electrodes fabricated at 900°C (t: 2 hours, h: 10°C/min) have been included. As demonstrated in a previous optimization work at 900°C, this process produced pyrolytic carbon with the best electrical and electrochemical properties at this temperature [30].

# 2.3. Structural characterization

The thickness of the carbon films was analyzed before and after pyrolysis using a stylus profiler (Dektak XTA, Bruker). Measurements were acquired in three different points on each sample and averaged. All the pyrolytic carbon films were characterized by Raman spectroscopy performed using a Raman microscope (DXR model, Thermo Fisher Scientific Inc.) with an excitation wavelength of 532 nm and 10 mW laser power. The obtained spectra were analyzed using the OMNIC software from Thermo Scientific and Matlab to perform a background correction. The roughness of carbon films was measured using Atomic force microscopy (AFM) using a DME dualscope DS 95 SPM (Danish Micro Engineering A/S, Denmark). The surface topography images of samples were acquired in tapping-mode with a silicon tip. Scan size was  $5\mu m \times 5\mu m$ .

# 2.4. Electrical characterization

The electrical characterization was performed with a custom-made four point resistance setup and the Van der Pauw method was used to measure the sheet resistance of the carbon films. The resistances  $R_A$  and  $R_C$  were measured in the electrode configuration defined in figure 1D as

$$R_A = \frac{V_{43}}{I_{12}}, R_C = \frac{V_{31}}{I_{24}}$$
 (eq. 2)

To obtain a more precise measurement, the reciprocal values  $R_A = \frac{V_{21}}{I_{34}}$  and  $R_C = \frac{V_{42}}{I_{13}}$  were measured and averaged with  $R_A$  and  $R_C$ . The sheet resistance  $R_S$  was calculated using a Matlab algorithm in accordance to

$$e^{(-\frac{\pi R_A}{R_S})} + e^{(-\frac{\pi R_C}{R_S})} = 1$$
 (eq. 3) [27]

The resistivity was subsequently calculated multiplying the sheet resistance value by the carbon film thickness after pyrolysis.

#### 2.5. Electrochemical characterization

The electrochemical characterization was performed on the 2D electrode chips using CV and EIS. The measurements were performed using a potentiostat (Autolab PGSTAT128N, Metronohm Autolab) and the software package NOVA was used to analyze the acquired data. The carbon electrode chips were subjected to an oxygen plasma treatment (0.5 bar) in an Atto Plasma System (Diener electronic) for 65 seconds with a power of 50 W to improve wettability [22]. The chips were subsequently placed in a PMMA-based self-aligning magnetic clamping system (figure 3) [31]. For every pyrolysis condition analyzed, three chips were used. CV and EIS measurements were acquired using 300  $\mu$ l 10mM ferriferrocyanide [Fe(CN)<sub>6</sub>]<sup>4-</sup>/[Fe(CN)<sub>6</sub>]<sup>3-</sup> in phosphate buffered saline (PBS), both purchased from Sigma–Aldrich. Cyclic voltammograms were acquired using a three-electrode configuration and a scan rate of 100 mV in a potential range from -600 mV to 600 mV. EIS measurements were performed using a two-electrode configuration (WE and CE) acquiring data in the frequency range of 0.1-10<sup>6</sup> Hz, applying a sinusoidal potential of 10 mV and acquiring 10 points/decade.

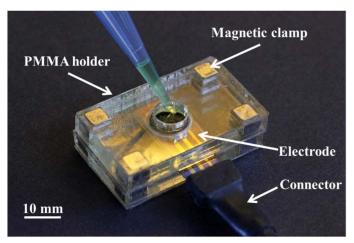


Figure 3. Magnetic clamping system.

3. Results and discussion

The variables for the experimental design for the pyrolysis process were dwell time t and heating rate h. The four measured responses were resistivity, anodic peak current, peak potential separation  $\Delta E_p$  and thickness after pyrolysis. For each factor, the terms that are statistically significant and thus have influence exhibit P-values lower than 0.05. To have an indication of the accuracy of the fitting, the coefficient of determination adjusted R<sup>2</sup> was calculated.

The P-values, adjusted  $R^2$  values and parameter estimates for the regression coefficients  $a_i$  with 95% confidence interval are reported (see Supplementary Material, S1).

#### 3.1. Thickness

Figure 4 reports the thickness values after pyrolysis. The final thickness of the carbon electrodes for all the samples is below 2  $\mu$ m, corresponding to a shrinkage above 80%. The results show that the heating rate was statistically significant with a P-value <0.05 and an effect size of -4.83±1.14  $\mu$ m. Previous studies have shown that SU-8-derived carbon films obtained with different pyrolysis processes exhibit a decrease in height which is more prominent for an increase in the final pyrolysis temperature [12]. In our case, we show that also the heating rate can have a significant influence on the thickness after pyrolysis. For faster ramps there is less time for rearrangement of carbon bonds during the heating step. This might result in increased mass loss due to evaporation of organic compounds and consequently a more prominent decrease in final film thickness.

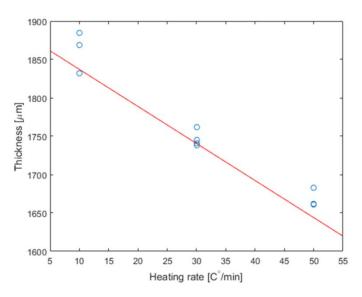


Figure 4. Thickness measurements for pyrolytic carbon films obtained at 1100°C using different dwell times in N2 (1 hour, 3 hours, 5 hours) and different heating rates (10°C/min, 30°C/min, 50°C/min).

#### 3.2. Raman spectroscopy

Raman spectroscopy was used to investigate the microstructure of the pyrolytic carbon and identify variations in the graphitic content due to different pyrolysis processes. All the spectra acquired showed the typical graphitic band (G-band) and amorphous band (D-band), characteristic for carbon materials (figure 5) [32]. The G band at 1590 cm<sup>-1</sup> is due to the  $E_{2g}$  vibration mode, related to the bond stretching of sp<sup>2</sup> hybridized C atoms present in the aromatic ring and olefinic chains [33]. The D band at 1330 cm<sup>-1</sup> originates from the activation of the breathing mode of  $A_{1g}$  symmetry in sp<sup>2</sup> C atoms and is related to defects and disorder in the graphite lattice[33]. It has been demonstrated that the ratio between the D

peak and the G peak intensities is inversely proportional to the crystallite size  $L_a : I_d/I_g \propto L_a$ , where  $I_d$  and  $I_g$  are the intensities of the D and G peaks respectively [32]. The increasing value of this ratio, and thus a smaller  $L_a$ , is an indicator of an increasing disorder [33].

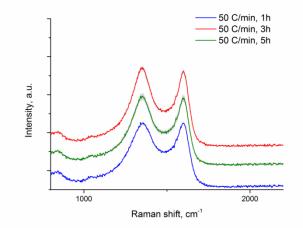


Figure 5. Raman spectra of samples pyrolyzed at 1100°C using different dwell times in N2 (1 hour, 3 hours, 5 hours) and heating rate of 50°C/min. Data are presented as mean  $\pm$  standard deviation (n = 3).

As shown in the representative Raman spectra reported in figure 5 and the values summarized in Table I, the samples pyrolyzed at 1100°C using different dwell times and heating rates in N<sub>2</sub> displayed similar  $I_d/I_g$  values. Different pyrolysis processes led to no measurable increase in the graphitic content, compared to the effects caused by a change of the final pyrolysis temperature [34].

<b>TABLE I.</b> Values (average±standard deviation, n=3) of peak intensity ratio of the D and G peaks					
	Id/Ig				
1h,10°C/min	1.10±0.004				
3h,10°C/min	1.02±0.007				
5h,10°C/min	1.03±0.010				
1h,30°C/min	0.99±0.003				
3h,30°C/min	$1.00\pm0.005$				
5h,30°C/min	1.01±0.004				
1h,50°C/min	0.99±0.003				
3h,50°C/min	1.05±0.003				
5h,50°C/min	1.02±0.002				

#### 3.3. Resistivity measurements

Resistivity values are reported here in order to study the influence of the pyrolysis parameters on the electrical properties of pyrolytic carbon. Figure 6A reports the resistivity values for pyrolytic carbon obtained at 1100°C with different pyrolysis conditions compared with the resistivity value for pyrolytic carbon obtained at 900°C. The temperature rise to 1100°C leads to a significant decrease of resistivity from  $9.3\pm0.8$  m $\Omega$ cm for the 900°C process to values lower than 4 m $\Omega$ cm for all the investigated conditions at 1100°C. These values are lower than other pyrolyzed photoresist films obtained with similar pyrolysis conditions: 6.8 m $\Omega$ cm for SU-8 pyrolyzed at 1000°C [25] and 5.1 m $\Omega$ cm for AZ photoresist pyrolyzed at 1100°C [11].

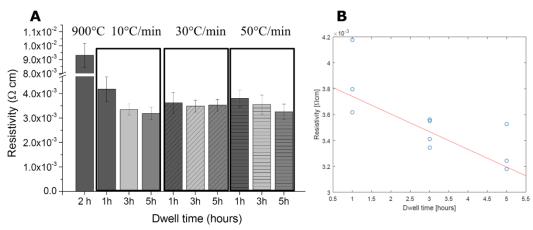


Figure 6. Resistivity measurements for pyrolytic carbon films obtained at 1100°C using different dwell times in N2 (1 hour, 3 hours, 5 hours) and different heating rates (10°C/min, 30°C/min, 50°C/min). Comparison with pyrolytic carbon obtained at 900°C (A) and influence of dwell time on resistivity values (B).

At 1100°C the general trend is a decrease of the resistivity values when the dwell time is increased (figure 6B). This is confirmed by the data analysis of the design of experiments results (Supplementary Material S1), where it can be seen that the dwell time is the only statistically significant factor with a pvalue of 0.04 and an effect size of  $-0.14 \pm 0.13$  m $\Omega$ cm. In particular, the lowest resistivity values were obtained for t=5 hours processes with h=10°C/min and h= 50°C/min:  $3.18\pm0.26$  m $\Omega$ cm and  $3.24\pm0.32$ m $\Omega$ cm respectively. Mardegan et al. showed a similar dwell time dependency at 900°C, where electrodes pyrolyzed for the longest time of 4 hours led to the lowest resistivity value measured [25]. Longer dwell times may provide longer time for the rearrangement of carbon atoms during the pyrolysis process and thus the formation of larger or differently oriented graphitic areas [25][35]. Alternatively, the lower resistivity for longer dwell times might be explained by partial annealing of the pyrolytic carbon film contributing to the formation of more graphitic carbon resulting in improved electrical properties. In related work, differences in the ratio between the graphitic (G) and amorphous (D) carbon peaks of Raman spectra have successfully been used to compare resistivity of samples pyrolyzed at different conditions [11]. However, as discussed above, the differences in Raman spectroscopy were insignificant in our studies. This indicates that the microstructural differences expected based on the electrical measurements are small and therefore could not be verified by Raman spectroscopy.

Focusing on the influence of the heating rate, the differences can be observed for the samples pyrolyzed with a heating rate of  $10^{\circ}$ C/min and  $50^{\circ}$ C/min, while there are no significant differences for the  $30^{\circ}$ C/min ramp rate. However this parameter was not found statistically significant for the resistivity.

# 3.4. Cyclic voltammetry

The 2D chips described in figure 1C were used to characterize the electrochemical behavior of the pyrolytic carbon. The electrochemical characterization provides information about the electron transfer process and the interaction between electrode surface and electrolyte. CV with the redox couple ferriferrocyanide  $[Fe(CN)_6]^{4-}$  /  $[Fe(CN)_6]^{3-}$  was used to evaluate and compare the performance of electrode chips pyrolyzed under different conditions.

To identify the best electrochemical behavior, the first parameter taken into account was the peak current. According to the Randles-Sevcik equation, the anodic and cathodic peak current values in CVs vary if the electrode area, diffusion coefficient, redox species, concentration or voltage scan rate are varied [36]. Since in our case all the experimental parameters are constant, a higher peak current value indicates a lower electrode resistance. The second parameter taken into account was the  $\Delta E_p$ , which for a reversible redox reaction is theoretically 59 mV. In principle, the optimal electrochemical behavior corresponds to large peak currents and low  $\Delta E_p$ .

Figure 7 reports representative voltammograms ( $h = 10^{\circ}$ C/min) comparing the electrochemical behavior for devices pyrolyzed at 900°C and 1100°C with the same heating rate but different dwell times. In Table II the values for the anodic peak current, cathodic peak current and  $\Delta E_p$  for the different analyzed conditions are reported. As it can be seen, there is an increase in the peak currents and decrease of  $\Delta E_p$ between electrodes obtained at 900°C and 1100°C. This is similar to what has been observed by others [10,11]. It can be explained by an improvement in the electron transfer due to a more conductive carbon fabricated at 1100°C, as confirmed by the resistivity measurements.

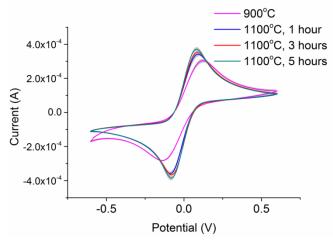


Figure 7. Voltammogram of pyrolytic carbon electrodes obtained at 900°C and 1100°C with a heating rate of 10°C/min acquired in 10mM ferri-ferrocyanide with a scan rate 100 mV/s. Data are presented as mean  $\pm$  standard deviation (n = 3).

<b>TABLE II.</b> Values (average±standard deviation, n=3) of anodic peak current and $\Delta$ Ep derived from CVs recorded with pyrolytic carbon microelectrodes fabricated with different pyrolysis heating rates and dwell times in 10mM [Fe(CN) <sub>6</sub> ] <sub>4-</sub> / [Fe(CN) <sub>6</sub> ] <sub>3-</sub> in PBS, scan rate 100 mV/s.					
Pyrolysis conditions	Anodic peak current (µA)				
900°C, 2h, 10°C/min	288.3±15.2	-253.4±3.3	239.3±9.8		
1h, 10°C/min	348.3±14.3	-364.4±15.4	$170.9 \pm 10.6$		
3h, 10°C/min	359.5±0.3	-375.7±0.4	159.5±2.8		
5h, 10°C/min	374.9±14.9	-390.1±16.4	161.7±11.7		
1h, 30°C/min	350.5±3.1	-364.8±4.4	180.7±7.3		
3h, 30°C/min	$352.1 \pm 10.1$	-366.2±10.9	181.5±4.4		
5h, 30°C/min	352.5±1.5	-368±0.6	167.8±5.4		
1h, 50°C/min	345.2±2.2	-354.7±1.2	173.3±6.5		
3h, 50°C/min	363.5±14.2	-378.3±16.4	$157.9 \pm 10.2$		

5h, 50°C/min 378.5±16.1 -392.3±13.6 153±11
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At 1100°C the voltammograms had a reproducible behavior, with small differences in peak current values and  $\Delta E_p$ . The data analysis confirmed that neither the dwell time nor the heating rate represented statistically significant parameters for peak current values, with all p-values being higher than 0.05 (Supplementary Material, S1). Compared to other work, the results indicate no significant change of surface area with increased heating rates. Recently Sharma et al. [26] showed that fast ramping rates (higher than 25°C/min) lead to porous pyrolytic carbon surfaces. However, investigation of the electrode surfaces using SEM and AFM confirmed smooth pyrolytic carbon surfaces in our case.

Singh et al. performed cyclic voltammetry on pyrolytic carbon electrodes fabricated at 1100°C using the same redox couple, but with different scan rates [14]. Comparing the peak current values from this study with our results, and taking into account the different working electrode areas and scan rates, we can conclude that the results are comparable.

For  $\Delta E_p$  both time and heating rate had a small influence, where processes with longer dwell times and higher heating rates showed smaller  $\Delta E_p$  values. This is confirmed by the p-values for the dwell time and heating rate squared, which are 0.05 and 0.04 respectively.

Combining the results obtained from the resistivity and the voltammetry measurements, the process that showed the best electrical and electrochemical properties was the the 5 hours process with a ramp of 50°C/min. For this reason, the electrodes obtained with these parameters were used for further electrochemical characterization. Different scan rates and concentrations were used to assess the reversibility of the electron transfer. For reversible systems such as  $[Fe(CN)_6]^{4-}$  /  $[Fe(CN)_6]^{3-}$  the peak currents should be directly proportional to the square root of the scan rate and concentration of the reactant, as described by the Randles-Sevcik equation [36].

Figure 8 shows the cyclic voltammograms recorded with different scan rates (100 mV/s, 50 mV/s, 25 mV/s, 15 mV/s, 10 mV/s) (Figure 8A) and concentrations of the redox probe  $[\text{Fe}(\text{CN})_6]^{4-}$  /  $[\text{Fe}(\text{CN})_6]^{3-}$  (20 mM, 10 mM, 5 mM, 2.5 mM, 1.25 mM) (Figure 8B) for the pyrolytic carbon electrodes. As shown in figure 8C and 8D, there was a linear relation of the peak current values with the square root of the scan rate and the redox probe concentration. Moreover, the  $\Delta E_p$  remained constant, as expected for a reversible electron transfer reaction. This showed that the electrode reaction was diffusion controlled and that pyrolytic carbon films exhibit a similar electrochemical behavior as glassy carbon [37].

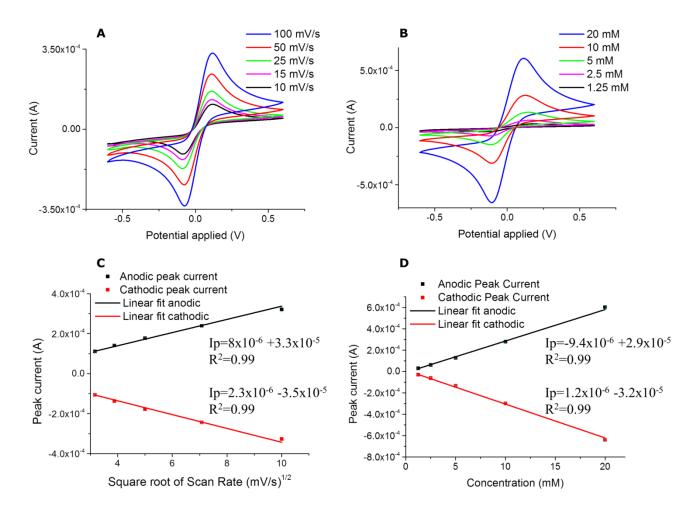


Figure 8. Voltammograms of pyrolytic carbon electrodes obtained at 1100°C (h= 50°C/min, t=5 hours) acquired in 10mM ferri-ferrocyanide varying scan rate (A) and concentration (B). Linear correlation between cathodic/anodic peak current and square root of scan rate (C) and the concentration (D).

### 3.5. Electrochemical impedance spectroscopy

EIS has been used as additional method to characterize the electrochemical properties of the pyrolytic carbon electrodes. This technique allows the evaluation of the resistance of the electrochemical setup, which is dependent on the properties of the electrode material but also depends on the overall measurement setup. Furthermore, through the evaluation of the charge transfer resistance, it is possible to gather information about the electrochemical reaction rate. In figure 9 the Nyquist plots for electrodes obtained at 1100°C are reported grouped by heating rates (10°C/min, 30°C/min, 50°C/min). The graphs plot the imaginary impedance component ( $Z_{imag}$ ) against the real impedance component ( $Z_{real}$ ) at each excitation frequency. All the electrodes showed a similar behavior, with a small capacitive semicircle in the high frequency region, a larger semicircle and a straight line in the lower frequency region. The larger semicircle is a result of the electron-transfer kinetics of the redox probe at the electrode interface, while the linear part at lower frequency is due to diffusion-limited electron-transfer processes. The diameter of the larger semicircle gives an indication of the charge transfer resistance ( $R_{ct}$ ), while the intercept with the real axis provides information on the solution resistance ( $R_{sol}$ ) and the electrode conductivity [36]. For the samples pyrolyzed with a heating rate of 10°C/min (figure9A) longer dwell times led to a smaller charge transfer resistance. The same

trend was observed for the heating rate of  $50^{\circ}$ C/min where the 5 hours process had the lowest R<sub>ct</sub>. On the other hand, samples pyrolyzed with a heating rate of  $30^{\circ}$ C/min showed no significant differences.

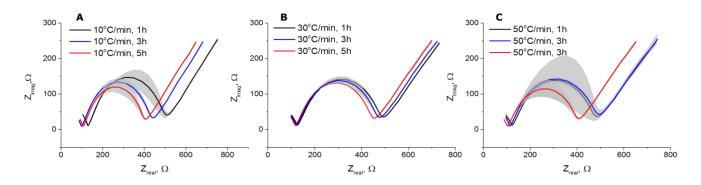


Figure 9. Impedance spectra of pyrolytic carbon electrodes obtained with different dwell times at 1100°C and different heating rates: 10°C /min(A), 30°C /min (B) and 50°C /min (C) acquired in 10mM ferri-ferrocyanide. Data are presented as mean ± standard deviation (n = 3)

An equivalent circuit, derived from a modified Randles model [38], was used to fit the impedance spectra obtained with different pyrolysis processes. Figure 10 shows the equivalent circuit used (inset) and the fitting for a representative Nyquist plot of an electrode obtained with a pyrolysis process of 5 hours at 1100°C with a heating rate of 50°C/min.  $R_b$  and  $C_b$  are the resistance and capacitance which are used to model the capacitive semi-circle in the high frequency region.  $R_{sol}$  represents the solution resistance, Y the magnitude of the constant phase element (CPE), *n* the multiplication factor of the phase angle,  $R_{ct}$  the charge transfer resistance and W the Warburg impedance. Figure 10 shows that throughout the entire frequency range the circuit provides an excellent fit to the experimental data.

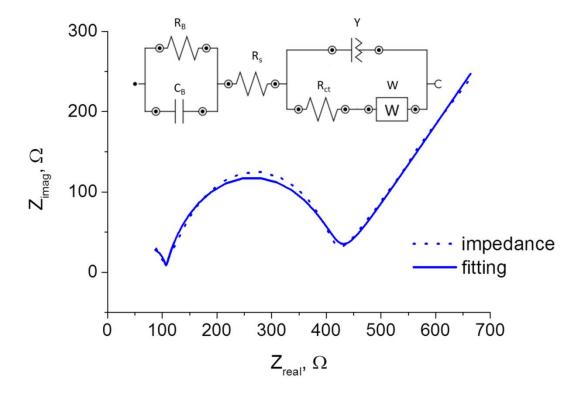


Figure 10. Nyquist plot of carbon electrode obtained at 5 hours at 1100°C in N2 with a heating rate of 50°C/min. Inset shows the corresponding equivalent circuit model.

TADIE III Values (average

<b>TABLE III.</b> Values (average±standard deviation, $n=3$ ) obtained from the fitting of the acquired impedance spectra. $C_B$ and							
R <sub>B</sub> are the capacitance and resistance, respectively, corresponding to the incomplete capacitive semi-circle at high							
frequencies; R <sub>ed</sub> is the solution resistance; Y is the magnitude of the constant phase element (CPE) and n is a constant							
between 1 and 0; $R_{ct}$ t is the charge transfer resistance; W is the Warburg impedance.							
	$C_{B}\left( nF ight)$	$R_{B}(\Omega)$	$R_{sol} (\Omega)$	Y (µMho)	п	$R_{ct}(\Omega)$	W (mMho)
1h,10°C/min	1.35±0.02	84.3±2.1	46.2±1.1	4.8±1.5	0.82±0.023	369.1±63	3.6±0.04
3h,10°C/min	$2.09\pm0.25$	51.4±4.4	48.6±2.3	3.8±0.2	0.82±0.006	333.8±22.2	3.7±0.02
5h,10°C/min	2.1±0.06	55.4±4	52.8±0.9	3.1±0.1	$0.84 \pm 0.002$	339.6±49.5	3.6±0.05
1h,30°C/min	1.47±0.09	80.2±6.4	46.3±1.1	4.1±0.1	0.81±0.004	358.1±13.3	3.7±0.02
3h,30°C/min	1.57±0.09	73.3.3	49.4±1.7	3.9±0.2	0.82±0.006	369±46.5	3.6±0.06
5h,30°C/min	$1.51 \pm 0.06$	71.6±1.9	46.5±0.6	3.5±0.2	$0.82 \pm 0.005$	327.7±7.9	3.6±0.06
1h,50°C/min	$1.85 \pm 0.66$	74.6±24.4	48.5±2	4.5±0.1	$0.80 \pm 0.004$	355.4±19.5	3.6±0.05
3h,50°C/min	$1.64\pm0.11$	67±1.8	47.6±2.8	5.2±1.1	0.82±0.018	370±142.6	3.5±0.14
5h,50°C/min	$1.80\pm0.14$	58.1±0.7	45.5±2.7	4.4±1.3	0.80±0.03	296.7.2±46.6	3.6±0.05

The values extracted from the fitting are reported in Table III. R<sub>b</sub> and C<sub>b</sub> are related to the bulk properties of pyrolytic carbon but also contain contributions of the overall electrochemical setup (e.g. contact resistances, parasitic capacitances) [38].  $Sp^2$  and  $sp^3$  regions inside the pyrolytic carbon lead to distributed resistances and capacitances. Higher values of  $R_b$  and  $C_b$  could be explained with larger sp<sup>3</sup> areas (insulating) resulting in a less conductive material. Table III shows that the values are in excellent agreement with the resistivity measurement performed with the Van der Pauw method, demonstrating a decrease of the R<sub>b</sub> values when the dwell time is increased. However this trend is not observable for C<sub>b</sub> and the main reason could be related with the equivalent circuit used: the part of the circuit composed of R<sub>b</sub> and C<sub>b</sub> might also be influenced by the resistance and capacitance contribution of the electrochemical setup. This kind of contribution should in principle be constant, but small variation can occur (e.g. leads and cable resistances). For this reason, in the opinion of the authors, trying to attribute an exact correlation between R<sub>b</sub>, C<sub>b</sub> and the pyrolytic carbon material properties might be error-prone.  $R_{sol}$  values represent the solution resistance, which in principle should be independent of the electrode material and as expected show small differences for the different pyrolysis processes. The 5 hours process with the 50°C/min heating rate showed the lowest R<sub>ct</sub> value, meaning that it provided a better electron transfer compared to the other electrodes. Among others, this parameter is related to the surface area of the electrode and a rougher surface leads to lower R<sub>ct</sub> values [39]. However, the differences between the various processes were small, meaning that electron transfer reaction rates were very similar, as confirmed by the comparable n values. The multiplication factor of the phase angle provides an indication of the roughness of the electrode surface, where a decreasing value of this parameter would indicate a more porous surface, and thus different electron transfer mechanisms [38]. AFM images were acquired to investigate the surface morphology of pyrolytic carbon obtained with different pyrolysis processes (Supplementary material S3). The root-mean square roughness measured by AFM was 1.6 nm for the samples pyrolyzed for 5 hours at 50°C/min, 1.4 nm for 30°C/min and 1 nm for 10°C/min. These values are similar to the ones obtained in earlier studies on pyrolysed photoresists [1,13,20] .Slower heating rates might provide more time to the photoresist to release the internal gases (O and H in SU-8 structure) in order to obtain a surface with a negligible roughness [12]. On the other hand, higher heating rates would not allow this controlled gas release, and consequently lead to a rough surface due to formation of small bubbles containing the unreleased gases [26]. In our case the fastest heating ramp of 50°C/min led to a surface which is was only slightly rougher compared to the one obtained with the slowest heating rate of  $10^{\circ}$ C/min. Nevertheless, these results are in accordance with the electrochemical ones, where the comparable R<sub>ct</sub> and *n* values could be explained by the small surface roughness variations between samples obtained with different heating rates.

# 4. Conclusions

In this work, we focused on the improvement and characterization of 2D carbon electrodes obtained from negative epoxy based photoresist SU-8 with a pyrolysis process at  $1100^{\circ}$ C in N<sub>2</sub>. The influence of pyrolysis parameters such as heating rate and dwell time at the maximum temperature was investigated.

The obtained pyrolytic carbon showed excellent electrical properties, with lowest resistivity value of  $3.2\pm0.3 \text{ m}\Omega\text{cm}$ . The resistivity values reported here are to our best knowledge the lowest ones reported for pyrolyzed photoresist films [11,12]. Furthermore, the carbon electrodes exhibit a glassy carbon-like electrochemical behavior, with a diffusion controlled electrode process. The fabrication process showed high reproducibility, confirmed by the low standard deviation values and the similar values of the two center points of the experimental design.

The influence of the different parameters was smaller than expected if compared to what has been shown in previous studies, where the variation of pyrolysis parameters such as heating rate led to significant changes in the surface porosity of pyrolytic carbon [26].

Nevertheless, it was possible to identify a trend in the resistivity measurements, showing that for processes carried out with heating rates of 10°C/min and 50°C/min longer dwell times led to lower resistivity values. The same trend was observable with cyclic voltammetry and impedance spectroscopy, where the best results were obtained for the process carried for 5 hours and 50°C/min. The statistical fitting of the results confirmed that the dwell time is the most influencing parameter for the electrical and electrochemical properties. On the other hand, for the thickness after pyrolysis the heating rate is the most relevant parameter. In this case, the already considerable shrinkage during pyrolysis is increased for higher heating rates, with the lowest carbon thickness values reported for the 50°C/min processes.

This systematic study of different process parameters improves our understanding of the correlation between pyrolysis conditions and pyrolytic carbon material properties. Therefore, the results reported here can be useful for other future studies regarding the pyrolysis of polymer precursors to finely tune the pyrolytic carbon properties.

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# Supplementary material

### Table S1

**TABLE S1.** P-values of the DoE fit and  $R^2$  values. The four measured responses are resistivity, peak current,  $\Delta Ep$  and thickness after pyrolysis. Factors included in the model are time (*t*) and heating rate (*h*)  $t^2$  $h^2$ t h t\*h  $R^2$ Resistivity 0.04 0.85 0.46 1.00 0.39 0.36 Peak current 0.09 0.88 0.78 0.99 0.25 0.19

0.40

0.87

0.45

0.44

0.04

0.26

0.62

0.94

0.62

0.0003

#### Table S2

ΔЕр

Thickness

<b>TABLE S2.</b> Normalized parameter estimates with 95% confidence interval						
	t	h	t*h	$t^2$	$h^2$	$R^2$
Resistivity	-2.73E-4±2.61E-4	-1.85E-5±2.61E-4	1.11E-4±3.20E-4	1.23E-4±4.19E-4	-7.78E-7 <u>±</u> 4.19E-4	-2.73E-4±2.61E-4
Peak current	1.03E-5±1.26E-5	7.47E-7±1.27E-5	1.70E-6±1.55E-5	-1.28E-7±2.03E-5	9.88E-6±2.03E-5	1.03E-5±1.26E-5
ΔЕр	-7.05E-3±6.82E-3	-1.32E-3±6.82E-3	-2.80E-3±8.35E-3	3.33E-3±1.09E-2	-1.22E-2±1.09E-2	-7.05E-3±6.82E-3
Thickness	5.14±22.8	-96.6±22.8	1.75±27.9	11.4±36.5	17.1±36.5	5.14±22.8

Parameter estimates have been normalized to the range -1 to +1.

0.05

0.56

AFM images of pyrolytic carbon samples obtained with 5 hours pyrolysis processes at 10°C/min (A), 30°C/min (B) and 50°C/min (C). The AFM measurements were performed using a DME dualscope DS 95 SPM (Danish Micro Engineering A/S, Denmark). The surface topography images of samples were acquired in tapping-mode with a silicon tip. Scan size was  $5\mu m \times 5\mu m$ 

